

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Atty. Docket

KEES G.W. GOOSSENS ET AL.

PHNL 021426

SERIAL NO.: 10/539,362

GROUP ART UNIT: 1794

FILED: June 15, 2005

EXAMINER: E.E. Mulvaney

USE OF BI-LAYER PHOTOLITHOGRAPHIC RESISTS AS NEW MATERIAL FOR
OPTICAL STORAGE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

AMENDMENT UNDER 37 C.F.R. 1.111

In response to the Office Action mailed December 1, 2008,
please amend the above-identified application as follows: